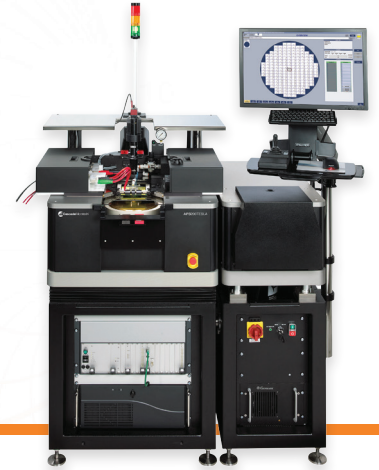


# ■ APS/SPS200TESLA

**200 mm Fully-automated On-Wafer  
Probing Solution for High-power Devices**

## DATA SHEET



The APS/SPS200TESLA is the industry's first fully-automated on-wafer probing solution focused on production performance for high-power semiconductors. The APS/SPS200TESLA improves productivity and yield at final test by enabling production wafer probing of high-power devices, increasing manufacturing margin and reducing your time-to-market. The APS/SPS200TESLA is designed to optimize the transition from device characterization through high-volume manufacturing, thereby optimizing your overall investment.

The APS/SPS200TESLA features a high-power auto-discharging chuck for thin- or Taiko-wafer handling and an anti-arcing solution to enable accurate and high-throughput measurements at high power. The APS/SPS200TESLA ensures precision production test up to 10.5 kV DC / 400 A, while providing a safe and regulatory-certified probing environment.

Using Velox™ probe station control software, the APS200TESLA enables safe and fast wafer loading and easy test automation and measurement system integration, while preventing damage of probe tips and probe cards throughout the entire measurement cycle. The VeloxPro™ test automation software is an open-architecture automation tool for fully-automated wafer probing. Compliant with SEMI E95, the VeloxPro easily enables automated wafer handling, cassette mapping, temperature control, Z-profiling and stepping. The APS200TESLA, powered by Velox and VeloxPro, achieves easy test automation and high test throughput.

## ■ FEATURES / BENEFITS

|                      |  |
|----------------------|--|
| Anti-arcing solution | Shielded system prevents arcing at higher voltages, protecting device and instrumentation from high-voltage discharge<br>Anti-arcing probe card prevents on-wafer arcing at higher voltages by providing compressed atmosphere<br>Anti-arcing solution allows optimal pad layout with smaller distance between pads, maximizing the wafer space<br>Uses clean dry air (CDA), eliminating the need to use any gas or liquid |
| MicroVac™ chuck      | Uniformly distributed vacuum holes provide low contact resistance across the entire wafer, ensuring accurate measurement results<br>Thin-wafer handling capability enables automatic Taiko wafer loading/handling down to 50 µm thickness and conventional wafer loading/handling down to 80 µm thickness<br>100 µm diameter vacuum holes prevent damage to thin wafer due to probe pin pressure                           |
| Safety               | Regulatory-certified probing environment to protect operators<br>Chuck auto-discharging capability to protect DUT from unexpected high-voltage discharge<br>Probe-pin touchdown sensor capability to prevent excess overdrive and ease setting probe-to-pad contact height   |

## MEASUREMENT PERFORMANCE

### Chuck Leakage

|         | Tested with SMU* |          | Tested with HiPot Tester** |          |          |
|---------|------------------|----------|----------------------------|----------|----------|
| 10 V    | 1000 V           | 3000 V   | 3000 V                     | 6000 V   | 10,000 V |
| < 10 pA | < 500 pA         | < 1.5 nA | < 1 nA                     | < 1.5 nA | < 3 nA   |

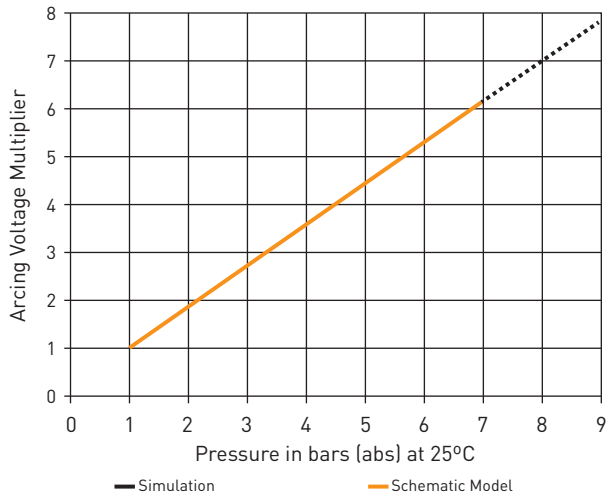
\* SMU testing conducted with Agilent B1505A HVSMU and measured with hold time of 10 sec.

\*\* HiPot testing conducted with Kyoritsu KEW3028 and measured at t = 120 sec.

### Auto-discharging Time (Typical)

|                         |        |
|-------------------------|--------|
| 10 kV discharged to 1 V | < 3 ms |
|-------------------------|--------|

### Anti-arcing High-pressure Probe Card Performance (Typical)



## MECHANICAL PERFORMANCE

|                            | X-Y Stage               | Z Stage                 | Theta Stage |
|----------------------------|-------------------------|-------------------------|-------------|
| Travel                     | 205 mm x 205 mm         | 15 mm                   | ± 6°        |
| Resolution                 | 0.5 µm                  | 0.25 µm                 | 0.00001°    |
| Repeatability              | ± 2 µm                  | ± 1 µm                  | < 2 µm**    |
| Accuracy (Precision Mode)* | ± 5 µm                  | ± 2 µm                  | NA          |
| Max. acceleration          | 596 mm/sec <sup>2</sup> | 596 mm/sec <sup>2</sup> | NA          |
| Max. velocity              | 49 mm/sec               | 18 mm/sec               | NA          |

\* (MAX ERR - MIN ERR) / 2 as measured at 60 locations.

\*\* Measured at edge of 200 mm chuck with standard moves.

## SYSTEM COMPONENTS FOR HIGH-POWER APPLICATIONS

|                                    |  |
|------------------------------------|--|
| Safety system                      | Integrated, easy-to-use safety enclosure with duplicated interlock functionality to ensure operator safety, and device protection                    |
| Instrument connectivity            | Dedicated instrument-to-station connection interface such as Agilent, ipTEST and others (available upon request)                                     |
| Anti-arcing probe card integration | Built-in probe card air control with interlock. Insulated, high-force probe card holder, and arc shielding system<br>Support for 10.5 kV probe cards |
| Contact sensor                     | Probe-to-pad contact detection under pressure  |
| Voltage discharge                  | Automatically discharge chuck between measurements in milliseconds   |
| Wafer alignment                    | On-axis probe-to-pad, and off-axis theta alignment optics  |
| Probe card holder                  | 4.5 inch probe card holder   |

## MICROVAC CHUCK

|                           |   |
|---------------------------|---|
| Max voltage and current*  | 10.5 kV DC / 400 A-pulsed**   |
| Chuck size                | 200 mm (Taiko and conventional wafer) or 150 mm (Taiko wafer)           |
| Material finish           | Gold-plated   |
| Flatness                  | < 15 $\mu$ m  |
| Supported wafer thickness | $\geq$ 50 $\mu$ m for Taiko wafer or other wafer types                  |
| Supported wafer diameter  | Shards or wafers from 3 inch through 8 inch                             |
| Vacuum hole diameter      | Approximately 100 $\mu$ m   |
| Number of vacuum holes    | Approximately 500 holes across 200 mm chuck                             |
| AUX chucks                | Two auxiliary locations for use with ISS, contact or cleaning substrate |

\* Contact Cascade Microtech for application-specific testing conditions and specifications.

\*\* Current duty cycle < 1% with max pulse width < 1 ms.

## WAFER-HANDLING ROBOT

|                                  |   |
|----------------------------------|---|
| Supported cassettes              | One SEMI E1 cassette ("H" bar design)   |
| Supported wafers                 | Conventional wafer: 3 inch to 8 inch<br>Taiko wafer: 6 inch to 8 inch   |
| Wafer handling                   | Conventional wafer (3 inch to 8 inch): Vacuum-end effector at wafer bottom side<br>Taiko wafer (6 inch to 8 inch): Optional vacuum-end effector |
| Cassette indexing                | Single beam laser reflection scanner  |
| Pre-aligner                      | Optical sensing, compatible with notch / flats  |
| Wafer ID reader                  | Optional top or bottom wafer ID reader  |
| Conventional wafer exchange time | ~ 58 sec (end of test to start of test)   |

## MACHINE TABLE

|                        |  |
|------------------------|--|
| Anti-vibration damping | Self-leveling air dampers or passive polymer dampers |
|------------------------|--|

The APS200TESLA is equipped with Velox probe station control software and VeloxPro user interface for test automation.

### Velox Probe Station Control Software

Velox software provides all features and benefits required for semi-automated operation of the probe system, such as:

- WaferMap with Z-profiling, sub-die stepping, binning and other useful features
- Configurable user interface and programmable buttons
- Intuitive GUI for efficient system utilization by novice and expert users
- Software joystick for precise, sub-micron positioning
- Easy integration with instruments, testers and measurement software for fast data collection

### VeloxPro User Interface for Test Automation

The APS200TESLA also includes VeloxPro user interface for test automation and automated wafer handling, featuring:

- Compliance to SEMI E95
- Cassette mapping and map visualization capabilities, with statistics and status view
- Test sequence customization
- Ability to load new wafers into the cassette while test is running on the chuck
- Screens for the setup of new recipes, parameters and pattern recognition
- Capability to accommodate multiple types of wafers in one cassette

### Tester Interface

The APS200TESLA uses commands through GPIB/TCPIP as master or slave. The GPIB/TCPIP interface provides the ability to:

- Request an inventory of all wafers available in the cassettes
- Define a wafer map
- Define a job (out of wafers and recipe)
- Initiate re-alignment
- Receive notifications when the wafer is aligned and ready to test

### Communication Ports

| Type            | Qty | Location                   | Notes  |
|-----------------|-----|----------------------------|--|
| LAN             | 1   | Rear system controller     | For factory integration                                  |
| USB 2.0         | 2   | Front of system controller | For USB drives, security keys and USB instrument control |
| RS232           | 1   | Rear system controller     | For instrument control                                   |
| GPIB IEEE 488.2 | 1   | Rear system controller     | For instrument control (optional)                        |

### Accessory Interface Ports

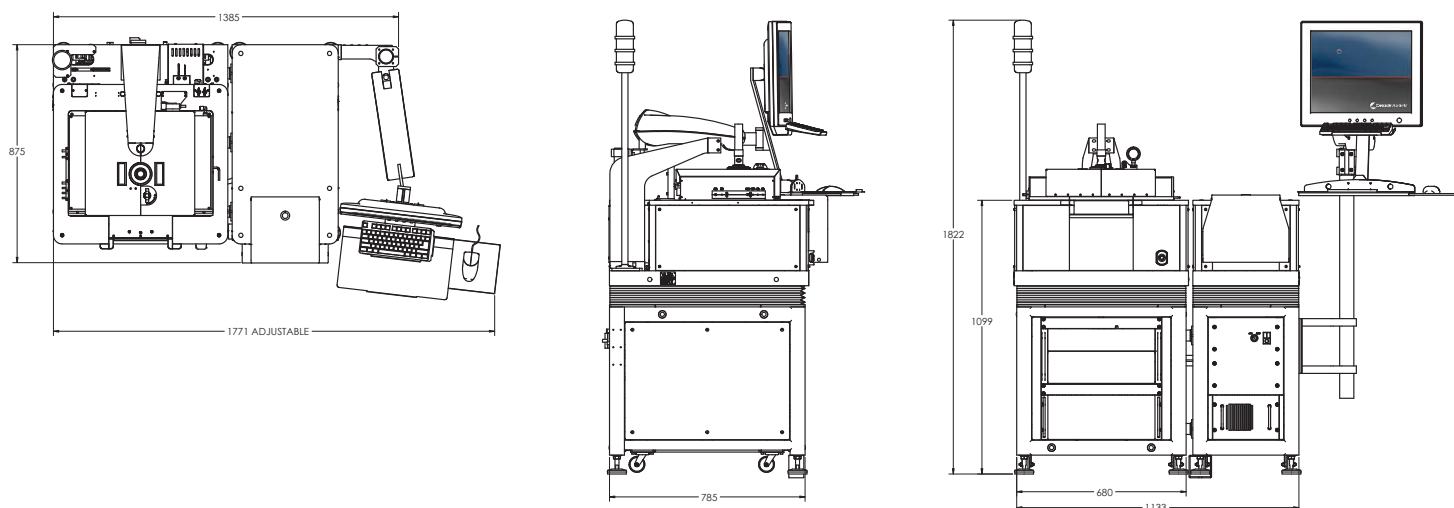
|            |   |                                    |   |
|------------|---|------------------------------------|---|
| EDGE SENSE | 1 | Connection panel at rear of platen | Probe card contact sense in addition to audible probe-to-pad contact detection under pressure |
|------------|---|------------------------------------|---|

## PHYSICAL DIMENSIONS

### Station Platform with Robot Handler

|                     |  |
|---------------------|--|
| Station dimensions* | Minimum: 1385 mm (W) x 875 mm (D) x 1822 mm (H)                      |
|                     | Station only (without loader): 932 mm (W) x 785 mm (D) x 1822 mm (H) |
| Weight              | Station: 475 kg, Loader: 250 kg                                      |

\*See drawings for detailed dimensions.



## FACILITY REQUIREMENTS\*

|   |   |
|---|---|
| Vacuum  | Less than 20 kPa absolute   |
|   | Flow rate 0.5 SCFM  |
|   | 8 mm hose [5/16-inch]   |
| Compressed air for vibration-isolation table and probe card | Filtered, dry and oil-free  |
|   | Minimum 0.65 MPa (6.5 bar) minimum to 0.8 MPa (8 bar) bar maximum |
|   | Flow rate 140 liters/min (5 SCFM)<br>8 mm hose [5/16-inch]        |
| Power   | 200-240 VAC nominal, 50/60 Hz, 500 VA                             |

\*See the Station Facility Guide for more details.

## AVAILABLE MODELS

| Part Number     | Description  |
|-----------------|--|
| APS200TESLA-010 | Fully-automated 200 mm on-wafer probe system for high-power devices, with a vibration isolation table and loader |
| APS200TESLA-020 | Fully-automated 200 mm on-wafer probe system for high-power devices, with a prober table and loader              |
| SPS200TESLA-010 | Semi-automated 200 mm on-wafer probe system for high-power devices, with a vibration isolation table             |
| SPS200TESLA-020 | Semi-automated 200 mm on-wafer probe system for high-power devices, with a prober table                          |

## AVAILABLE CHUCK OPTIONS

| Part Number | Description  |
|-------------|--|
| 158-870     | MicroVac chuck, coaxial, Au, 200 mm (8"), Taiko wafer ready* |
| 158-871     | MicroVac chuck, coaxial, Au, 150 mm (6"), Taiko wafer ready* |
| 158-050     | MicroVac chuck, coaxial, Au, 200 mm (8")                     |

\*Taiko wafer ready chuck designed to Disco Corp. maximum grind diameter and tolerance specifications.

## AVAILABLE INTERFACE KIT\*

| Part Number | Description  |
|-------------|--|
| 158-532     | Agilent B1505A with module selector interface assembly |
| 158-520     | ipTEST tester interface assembly                       |
| 162-800     | Agilent B1505A with UHCE or UHVE interface assembly    |

\*Additional interfaces are available upon request.

## STATION ACCESSORIES

| Part Number | Description              |
|-------------|--------------------------|
| 158-850     | Bottom-side reader       |
| 158-922     | Top-side reader          |
| 158-600     | 30U accessory rack       |
| 136687      | Rear shelf               |
| 155-496     | Optem Zoom 70 microscope |
| 158-860     | Auto-loader upgrade      |

## REGULATORY COMPLIANCE

|               |           |
|---------------|-----------|
| Certification | CE and CB |
|---------------|-----------|

## WARRANTY

|                   |   |
|-------------------|---|
| Warranty*         | Fifteen months from date of delivery or twelve months from date of installation |
| Service contracts | Single and multi-year programs available to suit your needs                     |

\*See Cascade Microtech's Terms and Conditions of Sale for more details.

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APS/SPS200TESLA-DS-0715



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